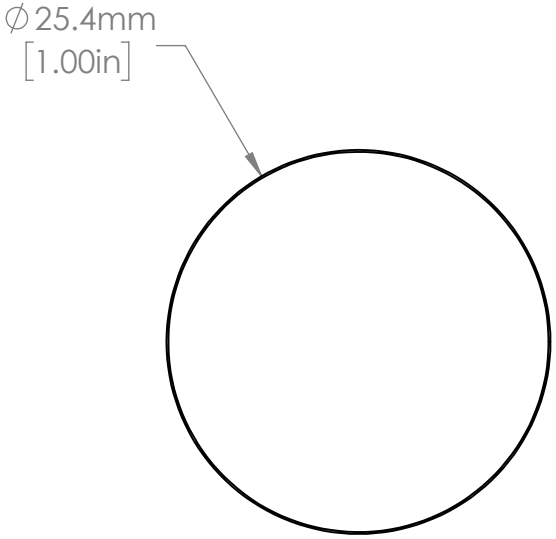
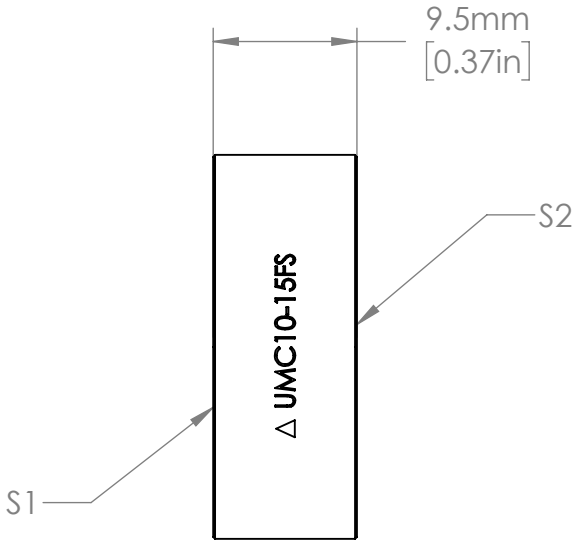






NOTES/SPECIFICATIONS:

1. CLEAR APERTURE: > 80% DIAMETER
2. SURFACE FLATNESS (S1): λ/4 AT 632.8 nm OVER CLEAR APERTURE
3. SURFACE QUALITY (S1): 15-5 SCRATCH-DIG
4. SURFACE (S2): POLISHED
5. PARALLELISM: ≤ 3 arcmin
6. THICKNESS TOLERANCE: ±0.20 mm
7. DIAMETER TOLERANCE: +0.00/-0.10 mm
8. COATING (S1)
   DESIGN WAVELENGTH RANGE: 650 nm - 1050 nm
   AOI: 10°
   R_s AND R_p: > 99.5% OVER WAVELENGTH RANGE
   GDD: -1.5 mm FUSED SILICA (-54 fs^2 @ 800 nm)

FOR INFORMATION ONLY
NOT FOR MANUFACTURING PURPOSES

DRAWING PROJECTION		
	NAME	DATE
DRAWN	EH	11/FEB/19
APPROVAL	JE	29/MAY/19

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VALUES IN PARENTHESIS ARE CALCULATED AND MAY CONTAIN ROUNDOFF ERRORS

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∅25.4 mm CHIRPED MIRROR
650 nm - 1050 nm, 10° AOI

MATERIAL	REV
FUSED SILICA	C

ITEM #	APPROX WEIGHT
UMC10-15FS	11 g